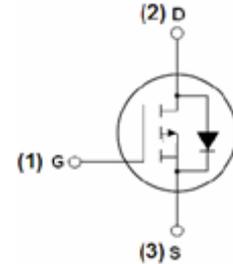


## Trench P-Channel PowerMOSFET Wafer Datasheet

### FEATURES

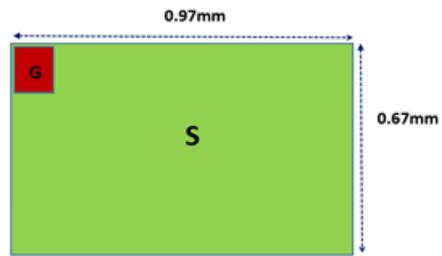
- -30V、4.5A\* , P-channel
- $R_{DS(on)}=65m\Omega(MAX)$
- Ultra low  $Q_{gd}$
- Fast switching



### Electrical Characteristics( $T_J=25^{\circ}C$ )

Parameter	Description	Min.	Typ.	Max.	Unit	Test Condition
$V_{(BR)DSS}$	Drain-Source Breakdown Voltage	-30			V	$V_{GS}=0V, I_D=-250\mu A$
$R_{DS(on)}$	Static Drain-Source On-Resistance		50	65	$m\Omega$	$V_{GS}=-10V, I_D=-2A$
			65	85	$m\Omega$	$V_{GS}=-4.5V, I_D=-2A$
$V_{GS(th)}$	Gate Threshold Voltage	0.7		1.4	V	$V_{DS}=V_{GS}, I_D=-250\mu A$
$I_{DSS}$	Drain-to-Source Leakage Current			1	$\mu A$	$V_{DS}=-30V, V_{GS}=0V, T_J=25^{\circ}C$
$I_{GSS}$	Gate-Body Leakage Current			$\pm 100$	nA	$V_{GS}=\pm 18V$
$V_{SD}$	Body Diode Voltage			1.5	V	$V_{GS}=0V, I_{SD}=-4.5A$
$T_J, T_{stg}$	Operating and Storage Temperature Range	-55~+125			$^{\circ}C$	

### Mechanical Data

Die Size	970×670	$\mu m^2$	
Gate Pad Size	150×150		
Source Pad Size	No Passivation		
Scribe Line Size	50	$\mu m$	
Wafer Diameter	200	mm	
Wafer Thickness	175	$\mu m$	
Passivation Frontside	No Passivation	---	
Source Metallization	AlCu , 4.0	$\mu m$	
Drain Metallization	Ti-Ni-Ag , 1K-2K-10K	A	
Reject Ink Dot Size	0.51	mm	
Recommended Storage Environment	Store in original container, in desiccated nitrogen, with no contamination		

\* Electrical characteristics are reported for the reference packaged part (SOT23\SOP8) and can not be guaranteed in die sales form.

Variations in customer packaging materials, dimensions and processes may affect parametric performance.